

# ICP-OES Operation, Quality Control and Troubleshooting Training Course

23 – 27 August 2027
Lisbon

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Training Center

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**Ref:** 1823_236672 **Date:** 23 – 27 August 2027 **Location:** Lisbon **Fees:** 6500 Euro

## Overview

ICP-OES Operation, Quality Control and Troubleshooting Training Course is a one-week intermediate course for laboratory analysts, chemists, environmental testing personnel, quality-control professionals, and technical supervisors who leave with an ICP-OES Method and Control Workbook. The course connects plasma spectroscopy, sample preparation, calibration, interference control, data review, operator maintenance, and structured fault isolation. Agile Leaders Training Center delivers this course on ICP-OES laboratory operation.

## Who Should Attend

- Functions responsible for elemental analysis and instrument operation
- Teams responsible for laboratory quality control and result review
- Groups responsible for environmental, food, materials, and process testing
- Technical support functions responsible for routine instrument care
- Supervisors responsible for method performance and defensible reporting

The course assumes participants already perform analytical laboratory work and leaves out service-engineer repairs, instrument modification, and regulatory interpretation.

## Departments and Industries

The course supports laboratory functions responsible for elemental measurement and instrument performance.

- Environmental and water-testing laboratories
- Food, pharmaceutical, and consumer-product quality control
- Mining, metals, cement, and materials laboratories
- Energy, petrochemical, and process-industry laboratories
- Research, contract testing, and laboratory technical services

## Learning Objectives

By the end of this course, participants will be able to:

- Analyze ICP-OES plasma, sample-introduction, and optical functions.
- Apply safe startup, shutdown, and operating checks.
- Build calibration and analytical quality-control sequences.
- Evaluate spectral, physical, and matrix interferences.
- Diagnose sensitivity, precision, and stability faults.
- Use maintenance, performance, and reporting records.

## Course Agenda

## Day 1: Frame ICP-OES Operation

- Atomic Emission and Inductively Coupled Plasma Process Map
- Torch, RF System, Gas Flow, and Plasma Formation Model
- Nebulizer, Spray Chamber, Pump, and Drain Path Diagram
- Optical System, Detector, and Axial-Radial Viewing Map
- RF, Heat, Ultraviolet, Chemical, and Gas Safety Checklist

## Day 2: Prepare Samples and Methods

- Sample Receipt, Preservation, Digestion, and Dilution Workflow
- Standards, Blanks, Spikes, and Reference Material Preparation Record
- Wavelength, Background, and Viewing-Mode Selection Matrix
- Calibration Range, Curve, and Acceptance Criteria Worksheet
- Method Setup and Instrument Parameter Control Sheet

## Day 3: Control Analytical Quality

- Initial and Continuing Calibration Verification Sequence
- Blank, Duplicate, Spike, and Reference Material Control Chart
- Spectral Overlap and Background Correction Review Method
- Matrix Effects, Transport Efficiency, and Dilution Decision Tree
- Result Flags, Data Review, and Reporting Traceability Checklist

## Day 4: Maintain and Troubleshoot

- Daily, Weekly, and Monthly Operator Maintenance Schedule
- Torch, Injector, Nebulizer, Spray Chamber, and Tubing Inspection Guide
- Gas, Cooling, Exhaust, Interlock, and Optics Performance Checklist
- Sensitivity, Precision, Noise, and Drift Fault Isolation Tree
- Instrument, Sample, Introduction, and Software Cause Matrix

## Day 5: Practice ICP-OES Analysis

- Exercise: Build a Safe Startup and Readiness Check
- Exercise: Configure Calibration and Quality-Control Samples
- Exercise: Diagnose Spectral and Matrix Interference Evidence
- Exercise: Isolate Poor Sensitivity and Precision Causes
- Capstone Exercise: Build the ICP-OES Method and Control Workbook

## Practical Exercises

The course uses suggested activities to connect analytical evidence with controlled operator decisions.

- Suggested activity: map sample flow from preparation through plasma excitation and detection.
- Suggested activity: assemble calibration, blank, spike, duplicate, and reference-material controls.
- Suggested activity: compare interference evidence and select a documented corrective response.
- Suggested activity: use maintenance records and performance checks to isolate an operational fault.

## FAQs

### Who suits ICP-OES operation and troubleshooting training, and what does it assume?

ICP-OES operation and troubleshooting training suits laboratory personnel who already handle analytical samples, follow laboratory controls, or support elemental-analysis instruments.

### How does ICP-OES operator training differ from instrument service training?

ICP-OES operator training covers methods, quality control, routine authorized maintenance, performance checks, and fault isolation, while service training addresses internal repair and manufacturer-specific engineering procedures.

### How are ICP-OES spectral and matrix interferences controlled?

ICP-OES interferences are controlled through wavelength and background choices, sample preparation, dilution, matrix matching, internal controls, review of signal behavior, and documented verification.

### What causes poor ICP-OES sensitivity or precision?

Poor ICP-OES sensitivity or precision can follow standards, tubing, nebulizer condition, torch condition, spray-chamber performance, gas or cooling conditions, sample matrix, method settings, or instrument stability.

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## Conclusion

Participants take back an ICP-OES Method and Control Workbook. The workbook connects sample preparation, method settings, calibration, analytical controls, interference decisions, maintenance evidence, troubleshooting, and reporting records. It changes isolated instrument actions into a traceable laboratory workflow for consistent operation, review, and technical escalation.